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Sheng-Rui Jian, Chih-Yen Huang, Wen-Cheng Ke

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Sheng-Rui Jian ^{1*}, Chih-Yen Huang ¹ and Wen-Cheng Ke ²

¹ Department of Materials Science and Engineering, I-Shou University, Kaohsiung 840, Taiwan

² Department of Mechanical Engineering, Yuan Ze University, Chung-Li 320, Taiwan

* To whom correspondence should be addressed.

Tel: +886-7-6577711 ext. 3130; Fax: +886-7-6578444

Email: srjian@gmail.com

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